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APPLICATION NO.

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APPLICANT

HIDEYA KUMOMI

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FILING DATE

June 9, 2004

GROUP

NOT YET ASSIGNED

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT
MC	DE	196 51 003 A	06/04/98	Germany			No
MC	JPA	2003-037063	02/07/03	Japan			Abstract

OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)

MC		Robert S. Sposill, et al., "Sequential Lateral Solidification of Thin Silicon Films on SiO ₂ ", <i>Applied Physics Letters</i> , vol. 69, no. 19, November 4, 1996.

EXAMINER

/Marissa Chaet/

DATE CONSIDERED

11/02/2006

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.